Searches for User *gverbitsky* (Count = 37661)

Queries 37612 through 37661.

Fin	d		************
		Next	Oldest
	lit H	elp Ret	um

S37661	S# U	Jpdt	Database	Query	Time	Comment
(substrate 01-19 resistance or 16:51:13 substrate resistor) and (membrane or diaphragm) S37660 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/185) and 2006- (substrate 01-19 resistance or 16:46:38 substrate resistor) S37659 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD 374/185 2006- 01-19 16:46:08 S37658 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD ((MEMBRANE 2006- OR 01-19 DIAPHRAGM) 16:05:25 adj5 (resistance)) and (substrate adj5 resistance) S37657 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (MEMBRANE 2006- OR 01-19 DIAPHRAGM) 16:04:58 adj5 (resistance) S37656 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29 and (substrate or 01-19 wafer) and (MEMBRANE OR DIAPHRAGM) S37655 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29 and (MEMBRANE OR DIAPHRAGM) S37655 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29) and (substrate or 01-19 wafer) 15:23:21				(374/185 and	2006-	
Say Say		_			01-19	
S37660 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD(374/185) and 2006-(substrate or				resistance or	16:51:13	ļ
S37660 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD(374/185) and 2006- (substrate 01-19 resistance or 16:46:38 substrate resistor) S37659 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD374/185 2006- 01-19 16:46:08 2006- 0R 01-19 DIAPHRAGM) 16:05:25 adj5 (resistance) adj5 (resistance) and (substrate adj5 resistance) S37657 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD(MEMBRANE 2006- OR 01-19 DIAPHRAGM) 16:04:58 adj5 (resistance) S37656 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD(MEMBRANE 2006- OR 01-19 DIAPHRAGM) 16:04:58 adj5 (resistance) S37656 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD(374/29 and 2006- (substrate or 01-19 wafer) and 15:53:29 (MEMBRANE OR DIAPHRAGM) S37655 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD(374/29) and 2006- (substrate or 01-19 wafer) and 15:53:29 (MEMBRANE OR DIAPHRAGM) S37655 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD(374/29) and 2006- (substrate or 01-19 wafer) 15:23:21				substrate		
S37660 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD(374/185) and (substrate or oli-19 resistance or substrate resistor) S37659 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD 374/185 2006-01-19 16:46:08				resistor)) and		
S37660 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD(374/185) and 2006-(substrate 01-19 resistance or 16:46:38 substrate resistor) S37659 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD374/185 2006-01-19 16:46:08				(membrane or		
(substrate 01-19 resistance or 16:46:38 substrate resistor) \$\frac{837659}{837659} \frac{\text{U}}{\text{U}} \text{PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD} \text{374/185} \text{2006-} \text{01-19} \text{16:46:08} \text{2016-} \text{01-19} \text{16:46:08} \text{2016-} \text{0R} \text{01-19} \text{16:05:25} \text{adj5} \text{(resistance)} \text{) and (substrate adj5} \text{(resistance)} \text{) and (substrate adj5} \text{resistance)} \text{9GPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (MEMBRANE 0R 01-19) DIAPHRAGM) 16:04:58 adj5 (resistance)} \text{18:37656} \text{U} \text{PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD} \text{(374/29 and 2006-(substrate or 01-19) wafer)) and 15:53:29 (MEMBRANE 0R DIAPHRAGM) \text{DIAPHRAGM} \text{S37655} \text{U} \text{PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD} \text{(374/29) and 2006-(substrate or 01-19) wafer) 15:23:21}				diaphragm)		
(substrate 01-19 resistance or 16:46:38 substrate resistor) \$\frac{837659}{837659} \frac{\text{U}}{\text{U}} \text{PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD} \text{374/185} \text{2006-} \text{01-19} \text{16:46:08} \text{2016-} \text{01-19} \text{16:46:08} \text{2016-} \text{0R} \text{01-19} \text{16:05:25} \text{adj5} \text{(resistance)} \text{) and (substrate adj5} \text{(resistance)} \text{) and (substrate adj5} \text{resistance)} \text{9GPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (MEMBRANE 0R 01-19) DIAPHRAGM) 16:04:58 adj5 (resistance)} \text{18:37656} \text{U} \text{PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD} \text{(374/29 and 2006-(substrate or 01-19) wafer)) and 15:53:29 (MEMBRANE 0R DIAPHRAGM) \text{DIAPHRAGM} \text{S37655} \text{U} \text{PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD} \text{(374/29) and 2006-(substrate or 01-19) wafer) 15:23:21}	S37660	U	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD	(374/185) and	2006-	
S37659 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD374/185 2006-01-19 16:46:08		_			01-19	,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,
S37659 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD374/185 2006-01-19 16:46:08				resistance or	16:46:38	
O1-19 16:46:08				substrate resistor)	ı	
01-19 16:46:08	S37659	U	PGPB, USPT, USOC, EPAB, JPAB, DWPI, TDBD	374/185	2006-	
S37658 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD ((MEMBRANE 2006-OR 01-19 DIAPHRAGM) 16:05:25 adj5 (resistance) and (substrate adj5 resistance) S37657 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (MEMBRANE 2006-OR 01-19 DIAPHRAGM) 16:04:58 adj5 (resistance) S37656 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29 and (substrate or 01-19 wafer)) and 15:53:29 (MEMBRANE OR DIAPHRAGM) S37655 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29) and (substrate or 01-19 wafer) 15:23:21			, , , , , , , , , , , , , , , , , , , ,		01-19	
OR 01-19 DIAPHRAGM) 16:05:25 adj5 (resistance)) and (substrate adj5 resistance) S37657 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (MEMBRANE 0R 01-19 DIAPHRAGM) 16:04:58 adj5 (resistance) S37656 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29 and 2006-(substrate or 01-19 wafer)) and 15:53:29 (MEMBRANE OR DIAPHRAGM) S37655 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29) and 2006-(substrate or 01-19 wafer) 15:23:21					16:46:08	
OR 01-19 DIAPHRAGM) 16:05:25 adj5 (resistance)) and (substrate adj5 resistance) S37657 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (MEMBRANE 0R 01-19 DIAPHRAGM) 16:04:58 adj5 (resistance) S37656 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29 and 2006-(substrate or 01-19 wafer)) and 15:53:29 (MEMBRANE OR DIAPHRAGM) S37655 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29) and 2006-(substrate or 01-19 wafer) 15:23:21	S37658	U	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD	((MEMBRANE	2006-	
adj 5 (resistance)) and (substrate adj 5 resistance) S37657 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (MEMBRANE 2006- OR 01-19 DIAPHRAGM) 16:04:58 adj 5 (resistance) S37656 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29 and (substrate or 01-19 wafer)) and 15:53:29 (MEMBRANE OR DIAPHRAGM) S37655 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29) and 2006- (substrate or 01-19 wafer) 15:23:21		_		ÒR	01-19	
(resistance)) and (substrate adj 5 resistance) S37657 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (MEMBRANE 2006-OR 01-19 DIAPHRAGM) 16:04:58 adj 5 (resistance) S37656 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29 and 2006-(substrate or 01-19 wafer)) and 15:53:29 (MEMBRANE OR DIAPHRAGM) S37655 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29) and 2006-(substrate or 01-19 wafer) 15:23:21	ll			DIAPHRAGM)	16:05:25	
(substrate adj 5 resistance) S37657 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (MEMBRANE 2006-OR 01-19 DIAPHRAGM) 16:04:58 adj 5 (resistance) S37656 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29 and 2006-(substrate or 01-19 wafer)) and 15:53:29 (MEMBRANE OR DIAPHRAGM) S37655 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29) and 2006-(substrate or 01-19 wafer) 15:23:21				adj5		
S37657 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (MEMBRANE 2006-OR 01-19 DIAPHRAGM) 16:04:58 adj5 (resistance) S37656 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29 and (substrate or 01-19 wafer)) and 15:53:29 (MEMBRANE OR DIAPHRAGM) S37655 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29) and (substrate or 01-19 wafer) 15:23:21	ŀ					
S37657 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (MEMBRANE 2006-OR 01-19 DIAPHRAGM) 16:04:58 adj5 (resistance) S37656 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29 and (substrate or 01-19 wafer)) and 15:53:29 (MEMBRANE OR DIAPHRAGM) S37655 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29) and (substrate or 01-19 wafer) 15:23:21				`		
OR 01-19 DIAPHRAGM) 16:04:58 adj5 (resistance) S37656 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29 and 2006- (substrate or 01-19 wafer)) and 15:53:29 (MEMBRANE OR DIAPHRAGM) S37655 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29) and 2006- (substrate or 01-19 wafer) 15:23:21				,		
DIAPHRAGM) 16:04:58 adj5 (resistance) S37656 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29 and 2006- (substrate or 01-19 wafer)) and 15:53:29 (MEMBRANE OR DIAPHRAGM) S37655 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29) and 2006- (substrate or 01-19 wafer) 15:23:21	S37657	<u>U</u>				i i
adj 5 (resistance) S37656 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29 and 2006- (substrate or 01-19 wafer) and 15:53:29 (MEMBRANE OR DIAPHRAGM) S37655 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29) and 2006- (substrate or 01-19 wafer) 15:23:21	<u>li</u>					
S37656 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29 and 2006-(substrate or 01-19 wafer)) and 15:53:29 (MEMBRANE OR DIAPHRAGM) S37655 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29) and 2006-(substrate or 01-19 wafer) 15:23:21				,	16:04:58	
(substrate or 01-19 wafer)) and 15:53:29 (MEMBRANE OR DIAPHRAGM) S37655 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD(374/29) and 2006- (substrate or 01-19 wafer) 15:23:21				• •		
wafer)) and 15:53:29 (MEMBRANE OR DIAPHRAGM) S37655 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29) and 2006- (substrate or 01-19 wafer) 15:23:21	S37656	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD	(374/29 and		
(MEMBRANE OR DIAPHRAGM) S37655 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29) and 2006- (substrate or 01-19 wafer) 15:23:21				`		
OR DIAPHRAGM) S37655 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29) and 2006- (substrate or 01-19 wafer) 15:23:21					15:53:29	
DIAPHRAGM) S37655 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29) and 2006- (substrate or 01-19 wafer) 15:23:21				`		
S37655 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/29) and 2006- (substrate or 01-19 wafer) 15:23:21						
(substrate or 01-19 wafer) 15:23:21				,		
wafer) 15:23:21	S37655	<u>U</u>				
				•		
71				•		
S37654 U PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD374/29 2006-	<u>S37654</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD	374/29	2006-	

Page 2 of 6

<u>S37653</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/\$.ccls. an (MEMS) and (substrate or wafer or silicon)) and (disphragm or membrane)	01-19 15:23:05 d 2006- 01-19 15:13:32
<u>S37652</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/\$.ccls. an (MEMS)) and (substrate or wafer or silico	01-19 15:13:05
<u>S37651</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/\$.ccls.) a (MEMS)	•
<u>S37650</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD bulk adj5 silic	
<u>S37649</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD bulk silicon resistance	2006- 01-19 15:09:31
<u>S37648</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD bulk substrate resistance	2006- 01-19 15:08:36
<u>S37647</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (diaphragm temperature of temperature diaphragm) and (substrate temperature of temperature substrate or wafer temperature of temperature wafer)	14:34:52 ad
<u>S37646</u>	Ū	•	

Page 3 of 6 Show Saved Searches

<u>S37645</u>	<u>U</u>		(diaphragm resistance or resistance diaphragm) and (substrate resistance or resistance substrate or wafer resistance or resistance wafer)	2006- 01-19 14:23:27
S37644	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD	((diaphragm resistance)) and (substrate resistance)	2006- 01-19 14:21:27
S37643	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD	(diaphragm resistance)	2006- 01-19 14:21:10
<u>S37642</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD	(374/\$.ccls. and (temperature sens\$4 resist\$4 or temperature measur\$4 resist\$4) and (substrate or wafer)) and (diaphragm)	2006- 01-19 13:38:19
<u>S37641</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD	`	2006- 01-19 13:38:00
<u>S37640</u>	<u>U</u>	USPT	5177696.pn. and (second temperature or second resist\$4)	2006- 01-19 13:26:14
<u>\$37639</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD	•	2006- 01-19 12:53:20

'Show Saved Searches Page 4 of 6

<u>S37638</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD		2006- 01-19 12:26:04
<u>S37637</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD	(substrate or wafer)) and (membrane or frame) (374/\$.ccls. and (temperature sens\$4 resist\$4 or temperature measur\$4	2006- 01-19 12:25:51
<u>S37636</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD	(temperature sens\$4 resist\$4 or temperature	2006- 01-19 12:25:17
<u>S37635</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD	measur\$4 resist\$4) (membrane resistor or resistor membrane) and (substrate resistor	2006- 01-19 12:05:58
<u>S37634</u>	<u>U</u>		or wafer resistor)	2006- 01-19 11:42:41
S37633	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD	wafer resistance) (resistance membrane) and (resistance substrate or	2006- 01-19 11:39:59
S37632	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD	resistance wafer) resistance membrane	2006- 01-19
<u>S37631</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD	thermistor on membrane	11:39:41 2006- 01-19

Page 5 of 6 Show Saved Searches

S37630	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD wafer resist\$4	11:39:21 2006-
		and membrane resist\$4	01-19 11:38:17
<u>S37629</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (temperature measur\$3 wafer	
<u>S37628</u>	<u>U</u>	and "membrane" PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD temperature measur\$3 wafer	2006- 01-19 11:30:05
<u>S37627</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD temperature measur\$3	2006- 01-19
<u>S37626</u>	<u>U</u>	substrate PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD(374/\$.ccls. and (substrate adj temperature))	11:17:15 2006- 01-19 11:13:03
		and (membrane adj5 temperature or temperature adj5 membrane)	
<u>S37625</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/\$.ccls. and (substrate adj temperature)) and (mebrane adj5 temperature or temperature adj5 membrane)	2006- 01-19 11:09:30
<u>S37624</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/\$.ccls.) and (substrate adj temperature)	1 2006- 01-19 11:08:52
<u>S37623</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/\$.ccls. and (temperature adj: substrate)) and (membrane adj5	2006-
<u>S37622</u>	<u>U</u>	temperature) PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/\$.ccls. and (temperature adj. substrate)) and (temperature adj. membrane)	501-19
<u>S37621</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (374/\$.ccls.) and (temperature adj	501-19
<u>S37620</u>	<u>U</u>	substrate) PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (substrate temperature and (membrane temperature)) and (resist\$4)	10:59:50 2006- 01-19 10:30:09
<u>S37619</u>	<u>U</u>		2006-

Page 6 of 6 Show Saved Searches

l		tempe	rature) and	01-19
		(mem)		10:29:35
<u>S37618</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD substr tempe	rature	2006- 01-19 10:29:19
<u>S37617</u>	<u>U</u>		rate	2006- 01-19 10:23:10
<u>S37616</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (mem and (s resists	ubstrate	2006- 01-19 10:20:54
<u>S37615</u>	<u>U</u>	· ·	rate)) and	
<u>S37614</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (mem	sensor) substrate)	2006- 01-19 10:19:48
<u>S37613</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (mem and (3	374/\$.ccls.)	2006- 01-19 10:19:14
S37612	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD mem s		2006- 01-19 10:18:59

Find	d		
		Next	Oldest
Ed	it He	lp Ret	um

Freeform Search

	US Pre-Grant Publication Full-Text Database
	US Patents Full-Text Database
T	US OCR Full-Text Database
Database:	EPO Abstracts Database JPO Abstracts Database
	Derwent World Patents Index
	IBM Technical Disclosure Bulletins
	substrate resist\$4 same membrane resist\$4
Term:	

Display:	Documents in <u>Display Format</u> : - Starting with Number 1
Generate:	O Hit List O Hit Count O Side by Side O Image
90000000	
	Search Clear Interrupt

	Search History

DATE: Thursday, January 19, 2006 Printable Copy Create Case

<u>e Query</u>	Hit Count	Set Name			
e		result set			
DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ					
substrate resist\$4 same membrane resist\$4	3	<u>L13</u>			
substrate resist\$4 same diaphragm resist\$4	0	<u>L12</u>			
substrate resistir adj5 membrane resistor	0	<u>L11</u>			
substrate resistance adj5 membrane resistance	0	<u>L10</u>			
membrane in series substrate or substrate in series membrane	9 0	<u>L9</u>			
L7 and (membrane or diaphragm)	3	<u>L8</u>			
L6 and (substrate resistance or substrate resistor)	17	<u>L7</u>			
374/185	616	<u>L6</u>			
L4 and (substrate adj5 resistance)	276	<u>L5</u>			
(MEMBRANE OR DIAPHRAGM) adj5 (resistance)	11487	<u>L4</u>			
L2 and (MEMBRANE OR DIAPHRAGM)	7	<u>L3</u>			
L1 and (substrate or wafer)	74	<u>L2</u>			
374/29	293	<u>L1</u>			
	grb, USPT, USOC, EPAB, JPAB, DWPI, TDBD; PLUR=YES; One substrate resist\$4 same membrane resist\$4 substrate resist\$4 same diaphragm resist\$4 substrate resisting adj5 membrane resistor substrate resistance adj5 membrane resistance membrane in series substrate or substrate in series membrane L7 and (membrane or diaphragm) L6 and (substrate resistance or substrate resistor) 374/185 L4 and (substrate adj5 resistance) (MEMBRANE OR DIAPHRAGM) adj5 (resistance) L2 and (MEMBRANE OR DIAPHRAGM) L1 and (substrate or wafer)	substrate resist\$4 same membrane resist\$4 substrate resist\$4 same diaphragm resist\$4 substrate resist\$4 same diaphragm resist\$4 substrate resistir adj5 membrane resistor substrate resistance adj5 membrane resistance membrane in series substrate or substrate in series membrane L7 and (membrane or diaphragm) L6 and (substrate resistance or substrate resistor) 374/185 L4 and (substrate adj5 resistance) (MEMBRANE OR DIAPHRAGM) adj5 (resistance) L1 and (substrate or wafer) 74			

END OF SEARCH HISTORY

Freeform Search

Database:	US Pre-Grant Publication Full-Text Database US Patents Full-Text Database US OCR Full-Text Database EPO Abstracts Database JPO Abstracts Database Derwent World Patents Index IBM Technical Disclosure Bulletins
Term:	
Display:	10 Documents in <u>Display Format</u> : - Starting with Number 1
Generate:	: ○ Hit List ● Hit Count ○ Side by Side ○ Image
8000000	Search Clear Interrupt
	Search History

DATE: Thursday, January 19, 2006 Printable Copy Create Case

Set Name side by side	Query	<u>Hit</u> Count	Set Name result set
DB=R	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ		
<u>L43</u>	L40 and (substrate temperature or substrate resistance)	16	<u>L43</u>
<u>L42</u>	L41 and (membrane or frame)	19	<u>L42</u>
<u>L41</u>	L40 and (substrate or wafer)	95	<u>L41</u>
<u>L40</u>	L1 and (temperature sens\$4 resist\$4 or temperature measur\$4 resist\$4)	391	<u>L40</u>
<u>L39</u>	(membrane resistor or resistor membrane) and (substrate resistor or wafer resistor)	14	<u>L39</u>
<u>L38</u>	(membrane resistance or resistance membrane) and (substrate resistance or wafer resistance)	16	<u>L38</u>
<u>L37</u>	L36 and (resistance substrate or resistance wafer)	7	<u>L37</u>
<u>L36</u>	resistance membrane	1689	<u>L36</u>
<u>L35</u>	thermistor on membrane	0	<u>L35</u>
<u>L34</u>	wafer resist\$4 and membrane resist\$4	4	<u>L34</u>
<u>L33</u>	L32 and "membrane"	0	<u>L33</u>
<u>L32</u>	temperature measur\$3 wafer	53	<u>L32</u>
<u>L31</u>	temperature measur\$3 substrate	53	<u>L31</u>

Freeform Search Page 2 of 2

<u>L30</u>	L28 and (membrane adj5 temperature or temperature adj5 membrane)	6	<u>L30</u>
<u>L29</u>	L28 and (mebrane adj5 temperature or temperature adj5 membrane)	5	<u>L29</u>
<u>L28</u>	L1 and (substrate adj temperature)	290	<u>L28</u>
<u>L27</u>	L25 and (membrane adj5 temperature)	14	<u>L27</u>
<u>L26</u>	L25 and (temperature adj membrane)	0	<u>L26</u>
<u>L25</u>	L1 and (temperature adj5 substrate)	627	<u>L25</u>
<u>L24</u>	L23 and (resist\$4)	17	<u>L24</u>
<u>L23</u>	L22 and (membrane temperature)	22	<u>L23</u>
<u>L22</u>	substrate temperature	41448	<u>L22</u>
<u>L21</u>	L20 and (membrane)	2	<u>L21</u>
<u>L20</u>	L16 and (substrate resist\$4)	4	<u>L20</u>
<u>L19</u>	L18 and (membrane)	169	<u>L19</u>
<u>L18</u>	L16 and (substrate)	562	<u>L18</u>
<u>L17</u>	L16 and L1	1	<u>L17</u>
<u>L16</u>	mem sensor	807	<u>L16</u>
<u>L15</u>	L1 amd (MEM)	0	<u>L15</u>
<u>L14</u>	(substrate adj5 resistance) and (membrane adj5 resistance) and (temperature sensor or temperature indicator or thermal sensor)	7	<u>L14</u>
<u>L13</u>	(substrate resistance) and (membrane resistance) and (temperature sensor or temperature indicator or thermal sensor)	2	<u>L13</u>
<u>L12</u>	L1 and (temperature sens\$3 substrate)	18	<u>L12</u>
DB=	USPT; PLUR=YES; OP=ADJ		
<u>L11</u>	6131453.pn.	1	<u>L11</u>
DB = 0	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ		
<u>L10</u>	L9 and (membrane adj5 resistance)	0	<u>L10</u>
<u>L9</u>	L1 and (substrate adj5 resistance)	83	<u>L9</u>
<u>L8</u>	L1 and (substrate resistance)	11	<u>L8</u>
<u>L7</u>	L6 and (substrate)	1	<u>L7</u>
<u>L6</u>	L1 and (membrane resistance)	3	<u>L6</u>
<u>L5</u>	L3 and (membrane resistance)	0	<u>L5</u>
<u>L4</u>	L3 and (membrane)	83	<u>L4</u>
<u>L3</u>	L2 and (substrate)	927	<u>L3</u>
<u>L2</u>	L1 and (temperature sens\$3)	7420	<u>L2</u>
<u>L1</u>	374/\$.ccls.	28929	<u>L1</u>

END OF SEARCH HISTORY